

Submission Deadline—April 1, 2016



# Aberration Corrected Transmission Electron Microscopy

Spherical and chromatic aberration correctors in transmission and in scanning transmission electron microscopes (TEM/STEM) have become commercially available in recent years. They are comprised of electromagnetic multipoles driven by ultra-stable power supplies in conjunction with faster and more efficient hard- and software for image acquisition, analysis, and alignment. This technology has significantly improved the spatial resolution, down to the size of the Bohr radius under certain conditions so that the atomic scattering in the sample can limit the resolution, rather than the microscope.

Focus now needs to shift towards new scientific areas that can be addressed with this novel equipment, taking into account the improved resolution, reduced thermal drift, novel electron detectors, and larger pole-piece gaps, due directly or indirectly to the advent of aberration correction. The parameter space for operation has become much more complex, so operators need to carefully plan experiments to find the best way to extract meaningful data. In particular, the high voltage should be optimized to minimize radiation damage. Better resolution may involve higher electron doses but imply more beam damage. Increased stability allows fast experiments with highly focused electron probes. More sensitive detectors can be used to test new data acquisition schemes as well as to reduce the electron dose. Consideration must be given as to whether the fascinating *in-situ* studies of the kinetics of atomic growth mechanisms now possible will allow meaningful inference to be drawn on thermodynamic properties representative of the bulk. *In-operando* studies of specimens in their engineered application environment (i.e. in gaseous or liquid atmosphere, under electrical bias, strain, illumination, etc.) can be conducted at nano-scale resolution.

This Focus Issue will include imaging, spectroscopy, and diffraction based (S)TEM applications to materials science problems with planar or focused illumination.

Contributed articles are particularly sought in the following areas:

- · Resolution vs. quantification issues in quantitative high-resolution imaging
- · Quantitative spectroscopy for local measurements of chemistry or electronic properties
- + Limitations due to radiation damage
- + Comparing studies by planar and focused illumination: evaluating dose vs. dose rate effects
- · Applications of chromatic aberration correction, monochromation, and low energy studies
- Applications of improved electron detectors and novel acquisition schemes
- In-situ strain measurements and in-operando catalysis studies

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#### MANUSCRIPT SUBMISSION

To be considered for this issue, new and previously unpublished results significant to the development of this field should be presented. The manuscripts must be submitted via the *JMR* electronic submission system by **April 1, 2016.** Manuscripts submitted after this deadline will not be considered for the issue due to time constraints on the review process. **Submission instructions may be found at www. mrs.org/jmr-instructions.** Please select "Focus issue: *Aberration Corrected Transmission Electron Microscopy*" as the manuscript type. **Note our manuscript submission minimum length of 6000 words.** All manuscripts will be reviewed in a normal but expedited fashion. Papers submitted by the deadline and subsequently accepted will be published in the Focus Issue. Other manuscripts that are acceptable but cannot be included in the issue will be scheduled for publication in a subsequent issue of *JMR*.



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Cambridge University Press 32 Avenue of the Americas New York, NY 10013

ISSN: 0884-2914